Substitute for Form 1449 A & B/PTO Complete if Known 10/735,769 Application Number INFORMATION DISCHOO 3973 Confirmation Number STATEMENT BY APPLICANT Filing Date December 16, 2003 Koichi KAWAMURA First Named Inventor Art Unit 1756 (use as many sheets as necessary) **Examiner Name NOT YET ASSIGNED** Attorney Docket Number **O79007** Sheet of

			U.S. 1	PATENT DOCUME	ENTS	
Examiner	Cite No. ¹	Document Number		Publication Date		
Initials*		Number	Kind Code ¹ (if known)	MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	
		US				
		US				
		US				

FOREIGN PATENT DOCUMENTS								
Examiner Initials*	Cite No. ¹	Foreign Patent Document			Publication Date	Name of Patentee or		
		Country Code ³	Number ⁴	Kind Code ⁵ (if known)	MM-DD-YYYY	Applicant of Cited Document	Translation ⁶	
MD		ЕР	0 809 282	Al	11/26/1997	MAX PLANCK GESELLSCHAFT; CNRS SERVICE DE LA VALORISATIO (FR))		
				-			·	
				1				
	1							

NON PATENT LITERATURE DOCUMENTS						
Examiner Initials*	Cite Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazing No. 1 journal, serial, symposium, catalog, etc.), date, page(s), volume issue number(s), publisher, city, and/or country where publisher.					
M).		YOSHINOBU TSUJII ET AL.: "Fabrication of patterned high-density polymer graft surfaces. II. Amplification of EB-patterned initiator monolayer by surface-initiated atom transfer radical polymerization", POLYMER, ELSEVIER SCIENCE PUBLISHERS B.V, GB, vol. 43, no. 13, June 2002, pages 3837-3841, XP004349557				
M		RAHUL R. SHAH, ET AL., "Using atom transfer radical polymerization to amplify monolayers of initiators patterned by microcontact printing into polymer brushes for pattern transfer", MACROMOLECULES, vol. 33, no. 2, August 1, 2000, pages 597-605, XP002273494				
W		KRZYSZTOF MATYJASZEWSKI, et al., "Atom transfer radical polymerization", CHEMICAL REVIEWS, AMERICAN CHEMICAL SOCIETY. EASTON, US, vol. 101, no. 9, December 9, 2001, pages 2921-2990, XP002212148				
		YOUNAN XIA, ET AL., "Soft Lithography", ANGEWANDTE CHEMIE. INTERNATIONAL EDITION, VERLAG CHEMIE. WEINHEIM, DE, vol. 37, 1998, pages 550-575, XP002149045				
			<u> </u>			

		<u> </u>				
Examiner Signature	About Charle	Acris	Date Considered	10	01	105

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

^{&#}x27;Applicant's unique citation designation number (optional). ²See Kind Codes of USPTO Patent Documents at www.uspto.gov, MPEP 901.04 or in the comment box of this document. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST. 3). ⁴For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ³Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to indicate here if English language Translation is attached.